

10731109_CLS.txt
Most Frequently Occurring Classifications of Patents Returned
From A Search of 10/731,109 on September 02, 2005

Combined Classifications

| | |
|---|-------------|
| 9 | 365/230.06 |
| 6 | 257/E21.648 |
| 6 | 365/201 |
| 6 | 365/203 |
| 5 | 365/149 |
| 5 | 365/230.03 |
| 5 | 365/51 |
| 4 | 257/E21.582 |
| 3 | 257/296 |
| 3 | 257/E21.011 |
| 3 | 257/E21.166 |
| 3 | 257/E21.223 |
| 3 | 257/E21.309 |
| 3 | 257/E21.433 |
| 3 | 257/E21.437 |
| 3 | 257/E21.549 |
| 3 | 257/E21.551 |
| 3 | 257/E21.561 |
| 3 | 257/E27.089 |
| 3 | 365/154 |
| 3 | 365/189.05 |
| 3 | 365/200 |
| 3 | 365/207 |
| 3 | 365/208 |
| 3 | 365/222 |
| 3 | 365/49 |
| 3 | 438/692 |
| 3 | 438/705 |
| 3 | 438/753 |
| 2 | 216/38 |
| 2 | 216/87 |
| 2 | 257/773 |
| 2 | 257/776 |
| 2 | 257/E21.646 |
| 2 | 257/E23.144 |
| 2 | 365/189.01 |
| 2 | 365/189.11 |
| 2 | 365/190 |
| 2 | 365/205 |
| 2 | 365/210 |
| 2 | 365/230.01 |
| 2 | 365/230.09 |
| 2 | 365/233 |
| 2 | 365/63 |

Titles of Most Frequently Occurring Classifications of Patents Returned
From A Search of 10/731,109 on September 02, 2005

- 9 365/230.06 (3 OR, 6 XR)
Class 365 : STATIC INFORMATION STORAGE AND RETRIEVAL
365/230.01 ADDRESSING
365/230.06 .Particular decoder or driver circuit
- 6 365/201 (6 OR, 0 XR)
Class 365 : STATIC INFORMATION STORAGE AND RETRIEVAL
365/189.01 READ/WRITE CIRCUIT
365/201 .Testing
- 6 365/203 (1 OR, 5 XR)
Class 365 : STATIC INFORMATION STORAGE AND RETRIEVAL
365/189.01 READ/WRITE CIRCUIT
365/203 .Precharge
- 5 365/149 (0 OR, 5 XR)
Class 365 : STATIC INFORMATION STORAGE AND RETRIEVAL
365/129 SYSTEMS USING PARTICULAR ELEMENT
365/149 .Capacitors
- 5 365/230.03 (0 OR, 5 XR)
Class 365 : STATIC INFORMATION STORAGE AND RETRIEVAL
365/230.01 ADDRESSING
365/230.03 .Plural blocks or banks
- 5 365/51 (1 OR, 4 XR)
Class 365 : STATIC INFORMATION STORAGE AND RETRIEVAL
365/51 FORMAT OR DISPOSITION OF ELEMENTS

PLUS Search Results for S/N 10/731,109, Searched September 02, 2005 (Top 50)

The Patent Linguistics Utility System (PLUS) is a USPTO automated search system for U.S. Patents from 1971 to the present. PLUS is a query-by-example search system which produces a list of patents that are most closely related linguistically to the application searched. This search was prepared by the staff of the Scientific and Technical Information Center, SIRA.

6136642
6261964
6309975
6461967
4914502
5798975
4791611
5763323
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4855628
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4979177
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5218572
5231043
5237573
5258639
5265057
5268867
5272672
5276645
5278090
5278459
5278790
5289424
5291433
5301163



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Fri, 2 Sep 2005, 2:23:53 PM EST

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Search Query Display

Select a search number (#)
to:

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- Combine search queries using AND, OR, or NOT
- Delete a search
- Run a search

Recent Search Queries

- #1 ((bit line) or bitline<in>metadata) <and> ((word line) or wordline<in>metadata) <and> (layout <in>metadata)
- #2 ((bit line) or bitline<in>metadata) <and> ((word line) or wordline<in>metadata) <and> (layout <in>metadata)
- #3 ((bit line) or bitline<in>metadata) <and> ((word line) or wordline<in>metadata) <and> (layout and dram<in>metadata)
- #4 ((bit line) or bitline<in>metadata) <and> ((word line) or wordline<in>metadata) <and> (layout and dram<in>metadata)
- #5 ((bit line) or bitline<in>metadata) <and> ((word line) or wordline<in>metadata) <and> (layout and dram and trench<in>metadata)
- #6 ((bit line) or bitline<in>metadata) <and> ((word line) or wordline<in>metadata) <and> (layout and dram and trench<in>metadata)
- #7 ((bit line) or bitline<in>metadata) <and> ((word line) or wordline<in>metadata) <and> (layout and dram and trench<in>metadata)
- #8 ((bit line) or bitline<in>metadata) <and> ((word line) or wordline<in>metadata) <and> (layout and dram and trench<in>metadata)

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